

# Critical Research for Cost-effective Photoelectrochemical Production of Hydrogen

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This presentation does not contain any proprietary or confidential information

Project ID #  
170-PDP-35



A national laboratory of the U.S. Department of Energy  
Office of Energy Efficiency & Renewable Energy



# Overview

## Timeline

- Project start date: 10/13/2004
- Project end date: 10/12/2007
- Percent complete: 1%

## Budget

- Total project funding
  - DOE share: \$2,921,501
  - Contractor share: \$760,492
- Funding received in FY04 to date : 0
- Funding for FY05: ?

# Barriers addressed

- DOE MYPP Objective for PEC
  - By 2015, demonstrate direct PEC water splitting with a plant-gate hydrogen production cost of \$5/kg projected to commercial scale.
- Technical Targets:
  - 2010: STH Eff >9%; Durability >10,000 hours; Cost < \$22/kg
  - 2015: STH Eff >14%; Durability >20,000 hours; Cost < \$5/kg
- PEC Hydrogen Generation Barriers -- MYPP 3.1.4.2.3
  - M. Materials Durability
  - N. Materials and Systems Engineering
  - O. PEC efficiency

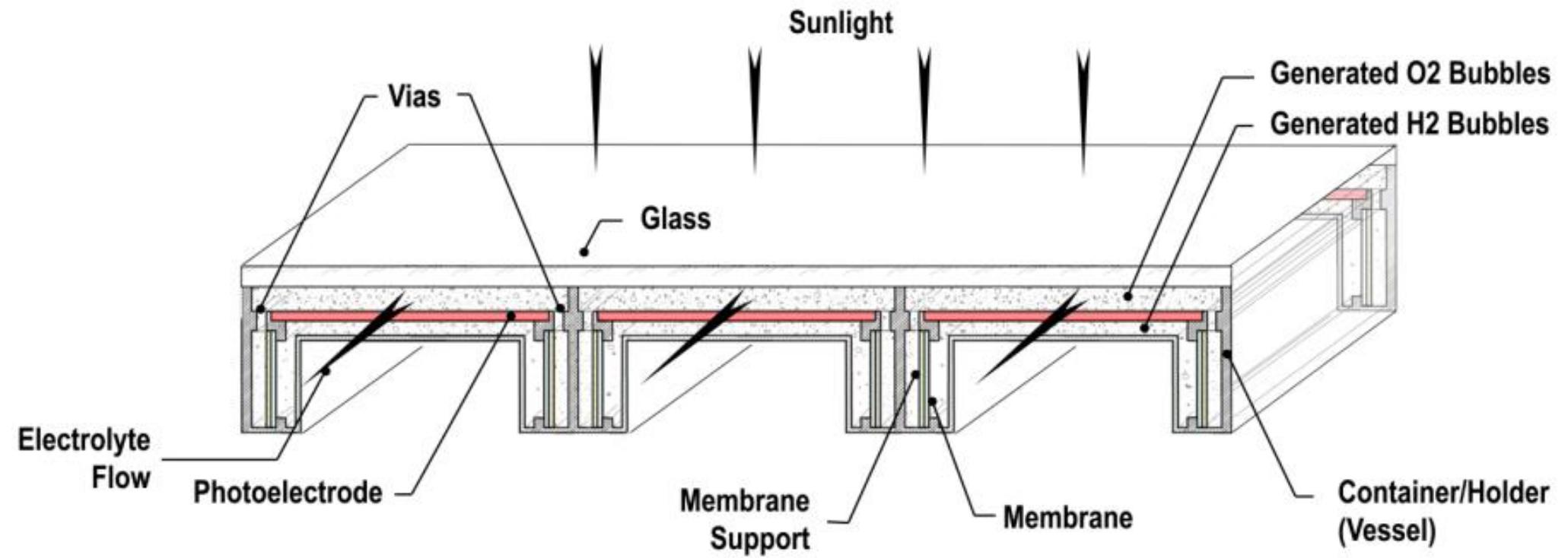
# Partners

- University of Toledo
- National Renewable Energy Laboratory
- United Solar Ovonic Corp.

# Objectives

- To develop critical technologies required for cost-effective production of hydrogen from sunlight and water using thin film-Si based photoelectrodes.
- To develop and demonstrate, at the end of the 3-year program, immersion-type tf-Si based PEC systems with 9% solar-to-hydrogen efficiency with a lifetime of 10,000 hours and with a potential hydrogen cost below \$22/kg.

# Approach - PEC cell

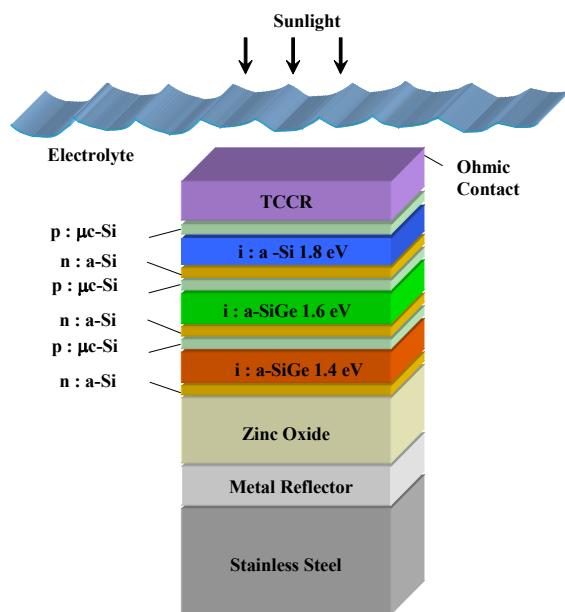


# Approach - PEC electrode

Two separate approaches for the development of high-efficiency and stable PEC photoelectrode:

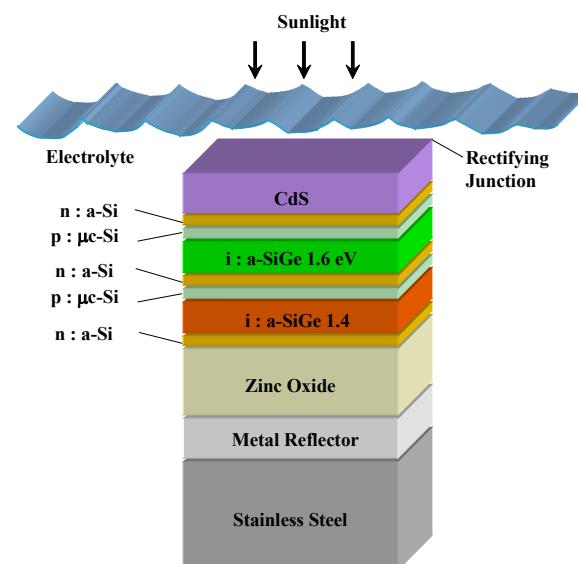
## Approach 1 (Task 1):

- Develop triple junction tf-Si photoelectrodes covered with a transparent, conductive, and corrosion resistant (TCCR) protection layer



## Approach 2 (Task 2):

- Develop hybrid, triple junction photoelectrodes with a semiconductor-electrolyte junction as the top junction and tf-Si alloys as the middle and bottom junctions



# Approach - Tasks

- Task 1: Transparent, conducting and corrosion resistant coating for triple-junction tf-Si based photoelectrode
- Task 2: Hybrid multijunction PEC electrode having semiconductor-electrolyte junction
- Task 3: Understanding and characterization of photoelectrochemistry
- Task 4: Fabrication of low-cost, durable and efficient immersion-type PEC cells and systems
- Task 5: Fabrication of 8ft<sup>2</sup>, substrate-type PEC panels

# Progress/Results

## DC Magnetron Sputter Deposition of $\text{TiO}_2$ , $\text{Fe}_2\text{O}_3$ and $\text{WO}_3$

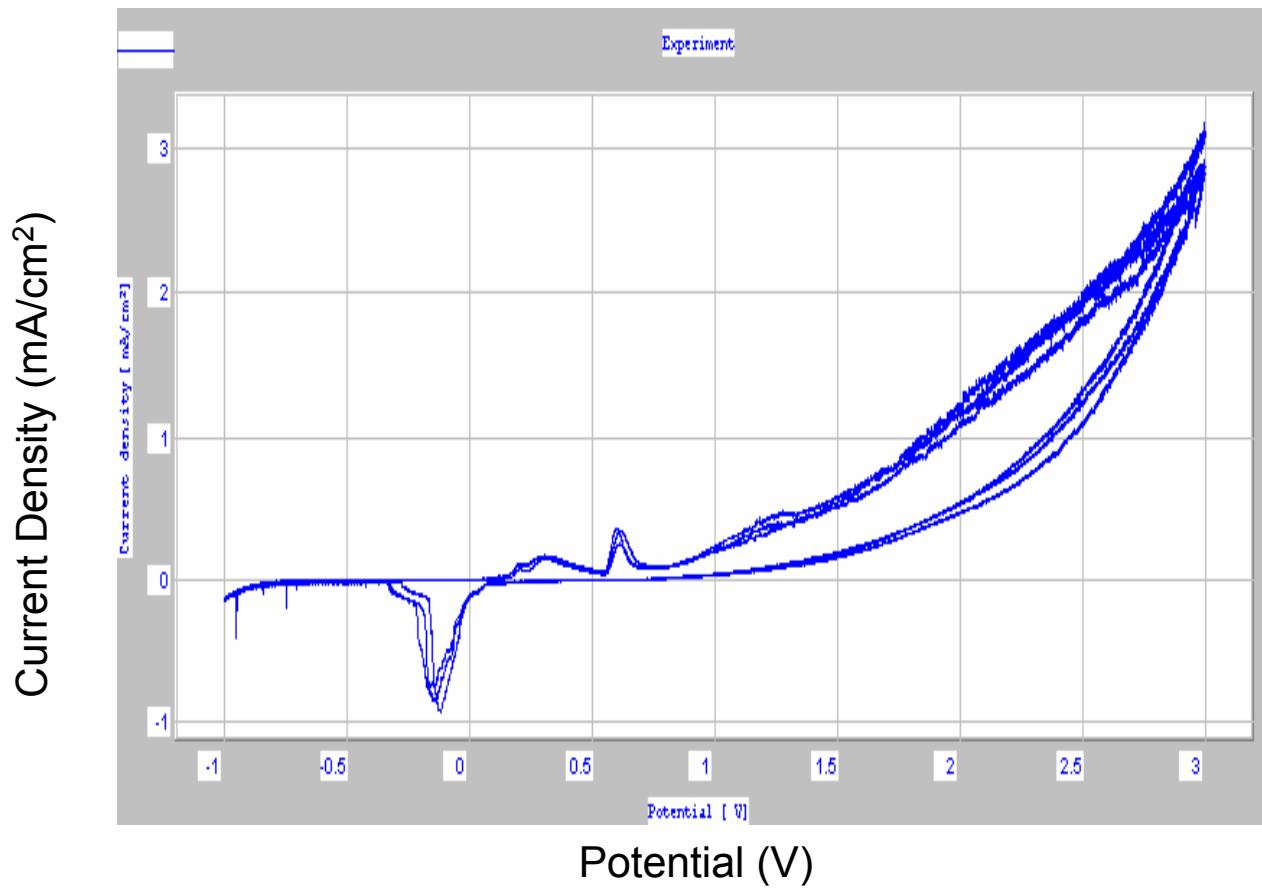
- Completed the construction of two new sputter deposition chambers for oxides depositions, with each chamber having three sputter targets capable of depositing from three different sources simultaneously
- Deposited  $\text{TiO}_2$ ,  $\text{Fe}_2\text{O}_3$  and  $\text{WO}_3$  films.
- For  $\text{TiO}_2$ , deposited films with
  - different oxygen content
  - different nitrogen doping
  - different indium doping

# Deposition Conditions for TiO<sub>2</sub> films

Sample	Power	Time	Temp	Pressure	Atmosphere	Comments	Sample	Power	Time	Temp	Pressure	Atmosphere	Comments
	(W)	(min)	(°C)	(mTorr)				(W)	(min)	(°C)	(mTorr)		
ST005	50	60	200	4	Ar	NONE	ST029	60	120	200	4	5% O <sub>2</sub> , Ar	NONE
ST006	50	60	250	4	Ar	NONE	ST030	60	120	250	4	5% O <sub>2</sub> , Ar	NONE
ST007	50	60	300	4	Ar	NONE	ST031	60	180	200	2	5% N <sub>2</sub> Ar	NONE
ST008	50	60	150	4	Ar	NONE	ST032	70	180	200	2	5% N <sub>2</sub> Ar	NONE
ST009	40	100	200	4	Ar	NONE	ST033	80	60	200	4	5% N <sub>2</sub> Ar	NONE
ST010	40	100	250	4	Ar	NONE	ST035	90	60	200	4	5% N <sub>2</sub> Ar	NONE
ST011	40	100	300	4	Ar	NONE	ST042	80	60	200	4	2% O <sub>2</sub> , Ar	In, 10 W
ST012	40	100	150	4	Ar	NONE	ST043	90	60	200	4	2% O <sub>2</sub> , Ar	In, 10 W
ST013	60	60	200	4	2% O <sub>2</sub> , Ar	NONE	ST045	90	60	200	4	2% O <sub>2</sub> , Ar	In, 15 W
ST014	60	60	250	4	2% O <sub>2</sub> , Ar	NONE	ST046	90	60	200	4	2% O <sub>2</sub> , Ar	In, 20 W
ST015	50	80	200	4	2% O <sub>2</sub> , Ar	NONE	ST047	80	60	200	4	30% N <sub>2</sub> Ar	NONE
ST016	40	100	200	4	2% O <sub>2</sub> , Ar	NONE	ST048	90	60	200	4	30% N <sub>2</sub> Ar	NONE
ST017	60	180	200	4	2% O <sub>2</sub> , Ar	NONE	ST049	80	60	250	4	30% N <sub>2</sub> Ar	NONE
ST018	30	120	200	4	2% O <sub>2</sub> , Ar	NONE	ST050	90	60	250	4	30% N <sub>2</sub> Ar	NONE
ST019	40	100	250	4	2% O <sub>2</sub> , Ar	NONE	ST051	100	60	200	4	30% N <sub>2</sub> Ar	NONE
ST020	50	80	250	4	2% O <sub>2</sub> , Ar	NONE	ST052	100	60	200	4	2% O <sub>2</sub> , Ar	In, 15 W
ST021	60	200	200	4	2% O <sub>2</sub> , Ar	NONE	ST053	100	60	200	4	2% O <sub>2</sub> , Ar	In, 20 W
ST022	40	100	150	4	2% O <sub>2</sub> , Ar	NONE	ST054	100	60	200	4	2% O <sub>2</sub> , Ar	In, 10 W
ST023	50	80	150	4	2% O <sub>2</sub> , Ar	NONE	ST056	100	60	200	4	2% O <sub>2</sub> , Ar	In, 7 W
ST024	40	300	200	4	2% O <sub>2</sub> , Ar	NONE	ST057	100	120	200	4	2% O <sub>2</sub> , Ar	In, 15 W
ST025	40	120	200	4	5% O <sub>2</sub> , Ar	NONE	ST059	100	120	250	4	2% O <sub>2</sub> , Ar	In, 15 W
ST026	40	120	250	4	5% O <sub>2</sub> , Ar	NONE	ST060	100	120	250	4	Ar/N <sub>2</sub> : 8/5 sccm	NONE
ST027	50	120	200	4	5% O <sub>2</sub> , Ar	NONE	ST062	100	120	250	4	Ar/N <sub>2</sub> : 8/5 sccm	4h anneal
ST028	50	120	250	4	5% O <sub>2</sub> , Ar	NONE							

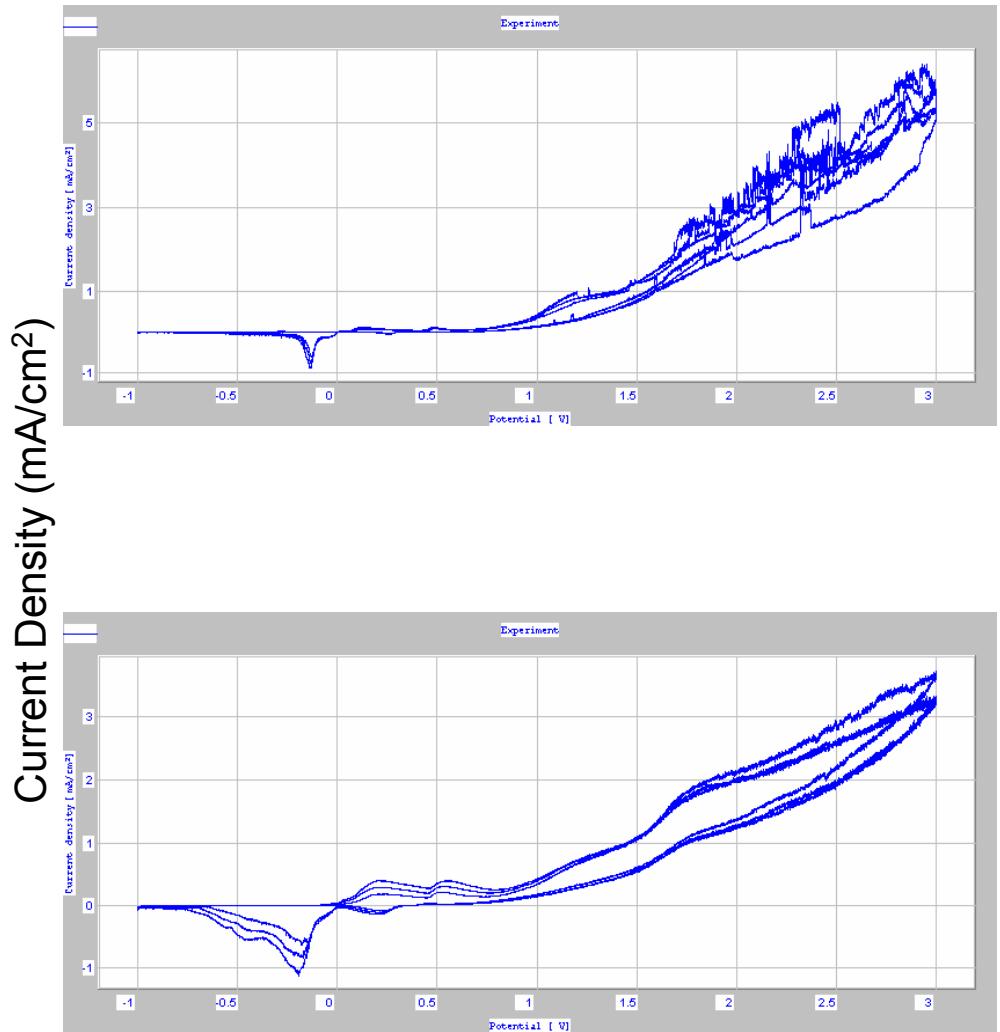
# TiO<sub>2</sub>

- I-V curve for TiO<sub>2</sub> shown in figure.
- Addition of small amounts of O<sub>2</sub> during TiO<sub>2</sub> deposition improves film's electrochemical stability



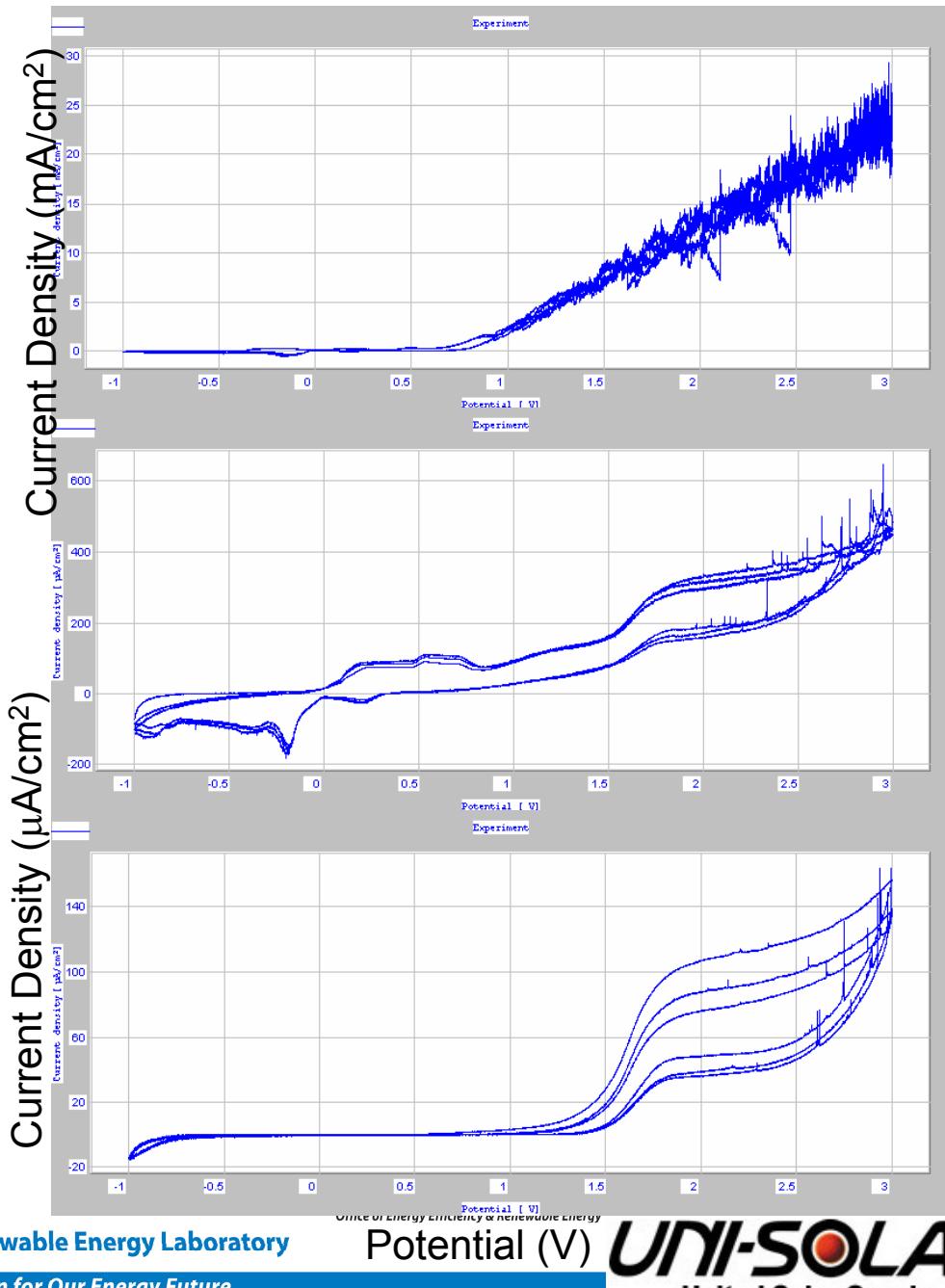
# TiO<sub>2-x</sub>N<sub>x</sub>

- (Top) Shows higher current density with no annealing, but still stable
- (Bottom) Annealing for 4 hrs, the film remained stable



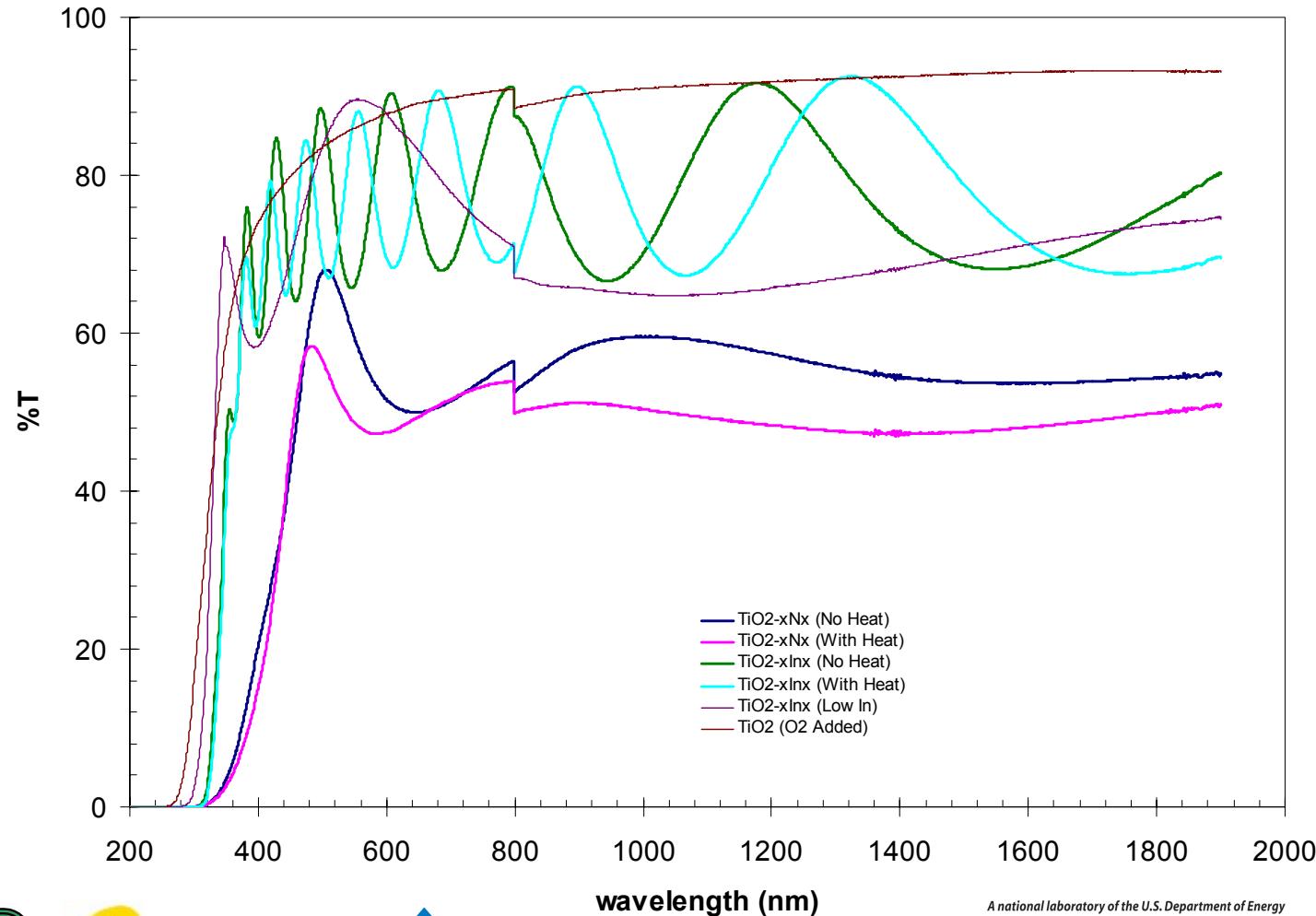
# $\text{TiO}_{2-x}\text{In}_x$

- (Top) Low amounts In dopant showed stability with larger current density
- Whereas (middle) shows lower current density with higher In conc., but still stable
- Photocurrent was observed only with the high levels of In
- For higher In sample, 4hr annealing improves stability of the film



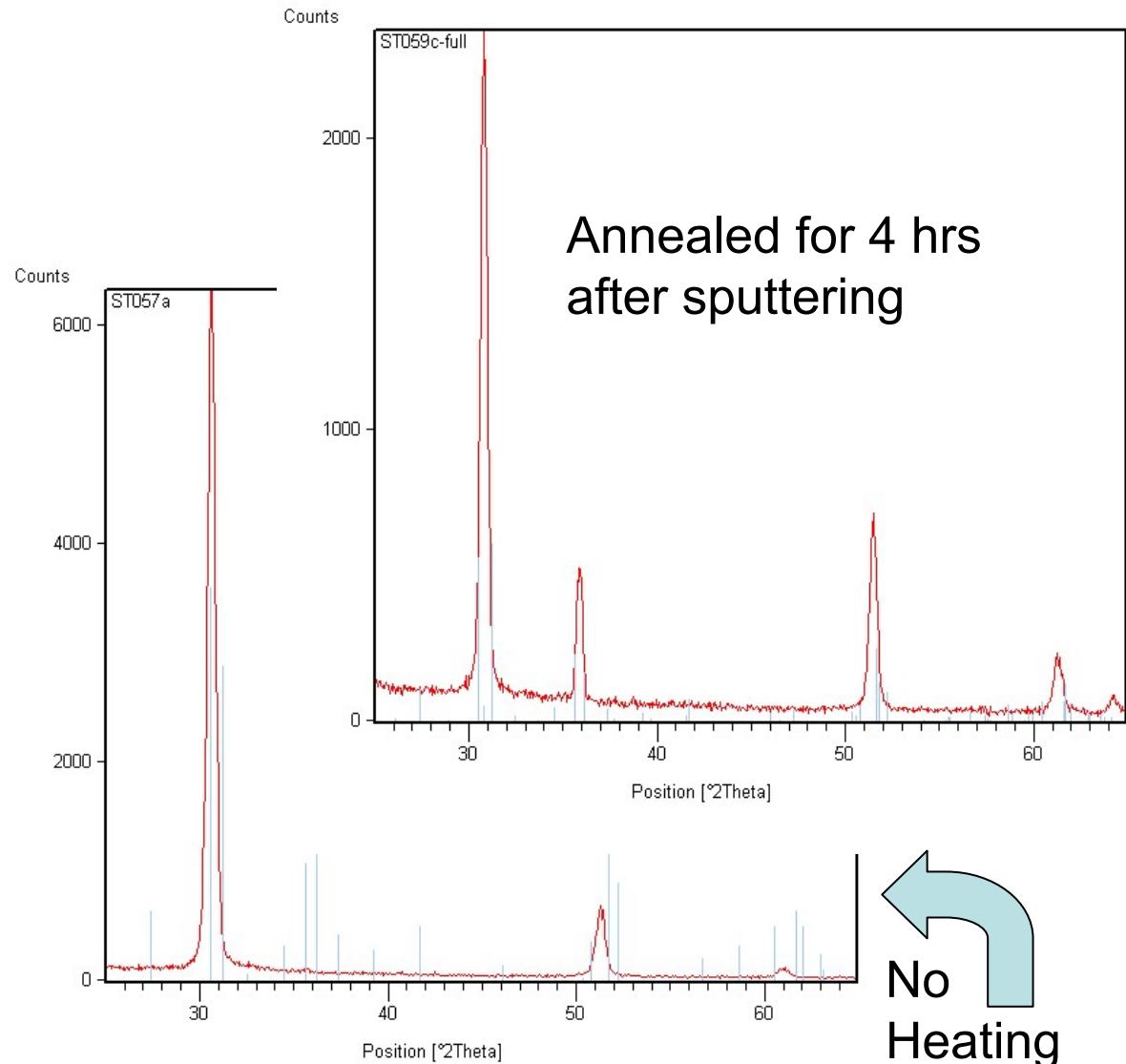
# Absorption Spectra for $\text{TiO}_2$

- $\text{TiO}_{2-x}\text{In}_x$  shows a similar absorption spectra to  $\text{TiO}_2$
- $\text{TiO}_{2-x}\text{N}_x$  shows improved absorption in the visible spectrum



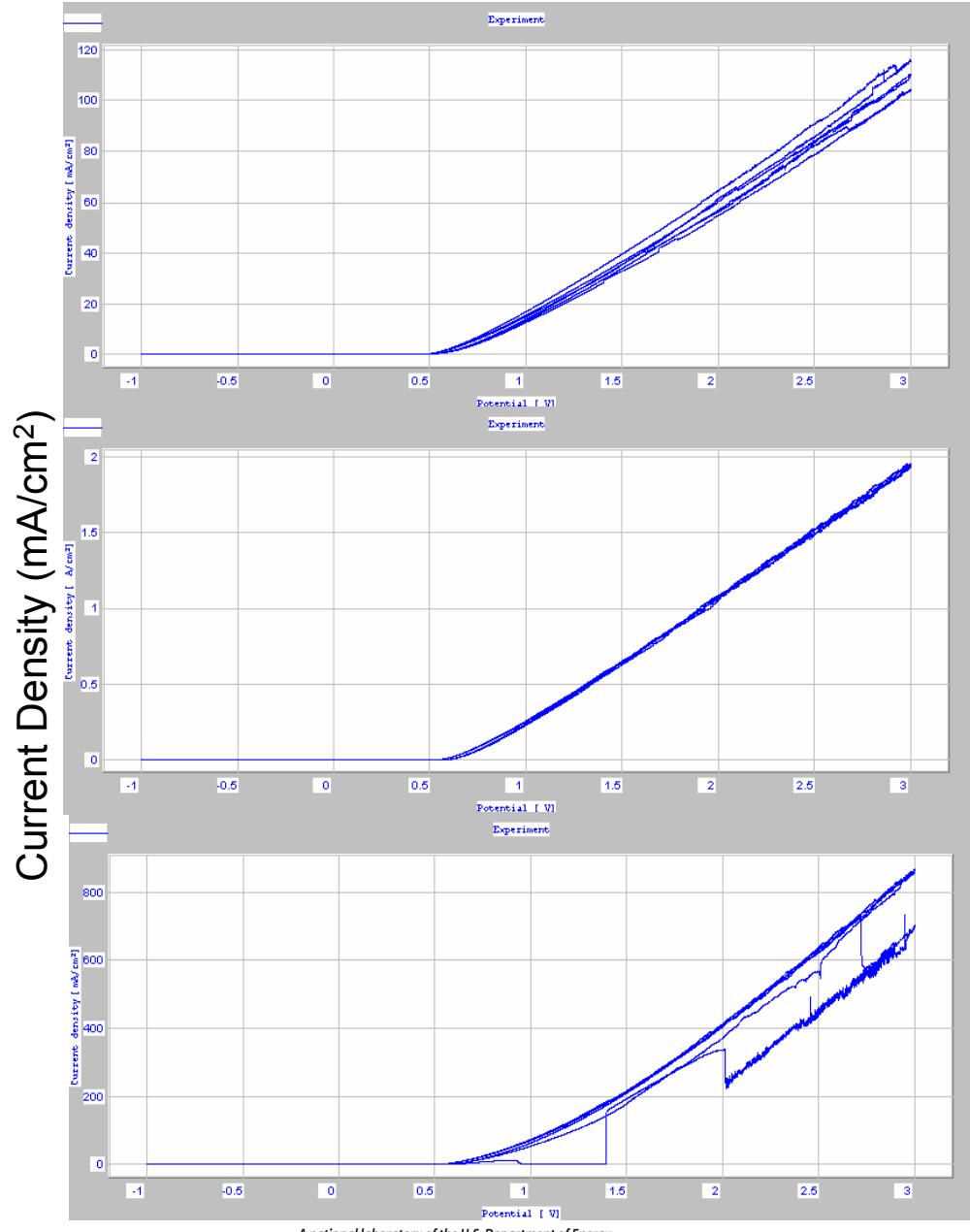
# X-ray Diffraction – $\text{TiO}_2$

- $\text{TiO}_{2-x}\text{In}_x$  exhibited crystallinity, which improved upon heating
- $\text{TiO}_2$  and  $\text{TiO}_{2-x}\text{N}_x$  showed no crystallinity with and without annealing
- Further testing will be performed to identify their structures



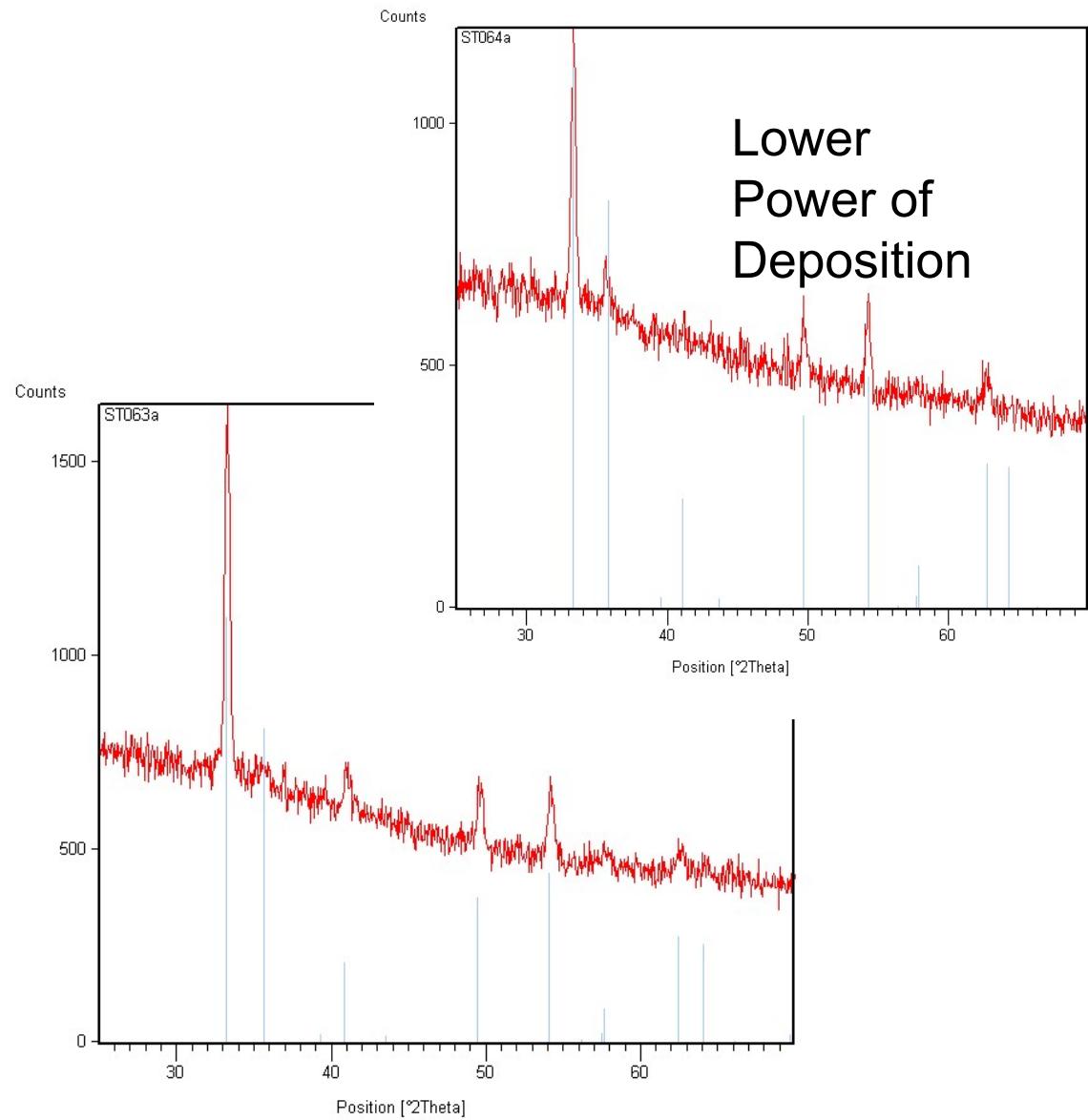
# I-V Measurements – $\text{Fe}_2\text{O}_3$

- Stable in 33% KOH standard solution
- Initial trials show high current density with excellent stability.
- I-V Curves for  $\text{Fe}_2\text{O}_3$  made with increasing power (50, 60, & 70 W)
- Lowest power showed minimal instability
- Absorption decreases with increased power used in deposition



# X-ray Diffraction – $\text{Fe}_2\text{O}_3$

- $\text{Fe}_2\text{O}_3$  exhibited crystallinity, which improved upon increased power during deposition
- Scans indicate the presence of hematite only in the films



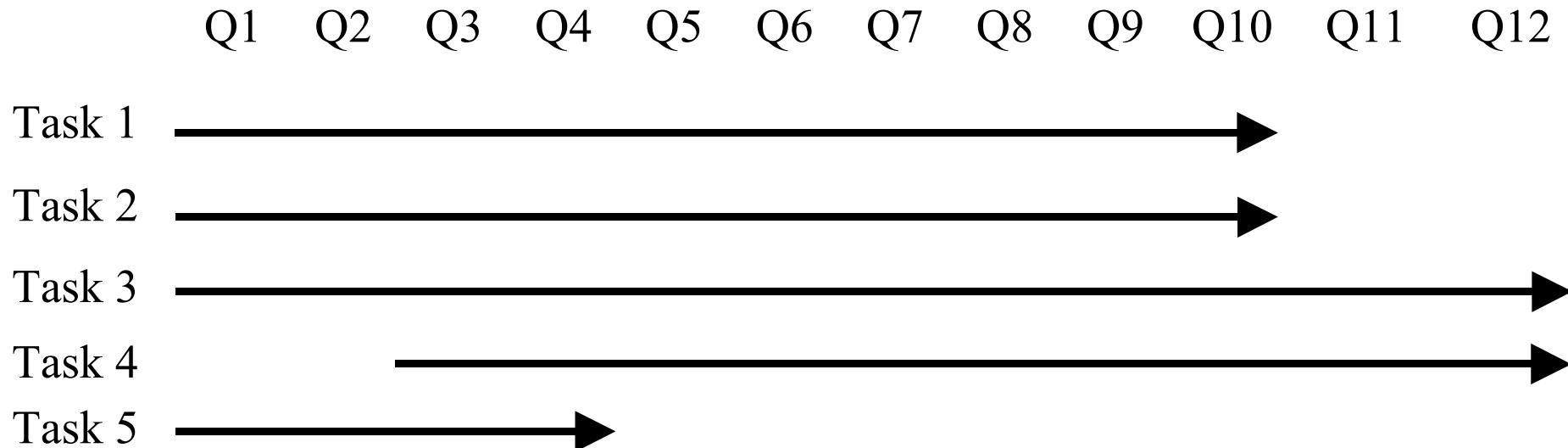
# Responses to Previous Year Reviewers' Comments

- N/A
- New Project



# Future Work

- Task 1: Transparent, Conducting and Corrosion Resistant coating for triple-junction tf-Si based photoelectrode
- Task 2: Hybrid multijunction PEC electrode having semiconductor-electrolyte junction
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# Publications and Presentations

“Development activities toward commercialization of photovoltaic hydrogen systems”, Liwei Xu, Presented at Northwest Ohio Alternative Energy Partnership Workshop, University of Toledo Student Union, Oct. 29, 2004.

“Renewable production of hydrogen from water using photoelectrochemical process”, Xunming Deng, presented at Purdue University “Hydrogen Economy” Colloquium, March 2, 2005.

Present MWOE’s superstrate-type PEC product at the Hydrogen and Fuel Cell Group Exhibit at Hannover Fair, Hannover, Germany, April 11-15, 2005

Demonstrated MWOE’s superstrate-type PEC product at COSI-Toledo (Toledo’s Science Museum) in its STRANGE MATTER special exhibit, Toledo, Ohio, April 17, 2005.



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# Hydrogen Safety

The most significant hydrogen hazard associated with this project is:

- Hydrogen generated from PEC panels needs to be appropriately handled.

Our approach to deal with this hazard is:

- Follow related federal and state guidelines for handling the hydrogen generated in our PEC panels
- Install adequate ventilations
- Provide safety training to all personals handling hydrogen

Other significant hazard related to this research is the handling of hazard gases such as  $\text{PH}_3$ ,  $\text{GeH}_4$ ,  $\text{SiH}_4$ ,  $\text{BF}_3$ ,  $\text{H}_2$  during the deposition of semiconductor layers for the photoelectrodes

- Have installed comprehensive safety measures for the handling of toxic gasses including
- toxic gas monitors probing various areas of deposition machines.
- The gas monitor can be accessed remotely and is monitored by police department.
- 24-hour training course has been provided to system operator.
- Visit by Toledo Fire department to discuss various safety issues.

# Collaborators

- **Midwest Optoelectronics, LLC**

Stanley Rubini

- **University of Toledo:**

Xunming Deng, Alvin Compaan, Robert Collins

Dean Giolando, Maria Coleman and A.H. Jayatissa

- **National Renewable Energy Laboratory**

John Turner

- **United Solar Ovonic Corp.**

Jeffrey Yang



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